

# Overview PhoeniX software

How to design a photonic chip?

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3/4/2015



This research project has been supported by a Marie Curie Early European Industrial Doctorates Fellowship of the European Community's Seventh Framework Programme under contract number (PITN-GA-2012-316596-ICE-DIP)

- PhoeniX's software packages
- Process Design Kits (PDKs) with PhoeniX software
- Example: How to design a Multimode-Interference-Coupler (MMI)

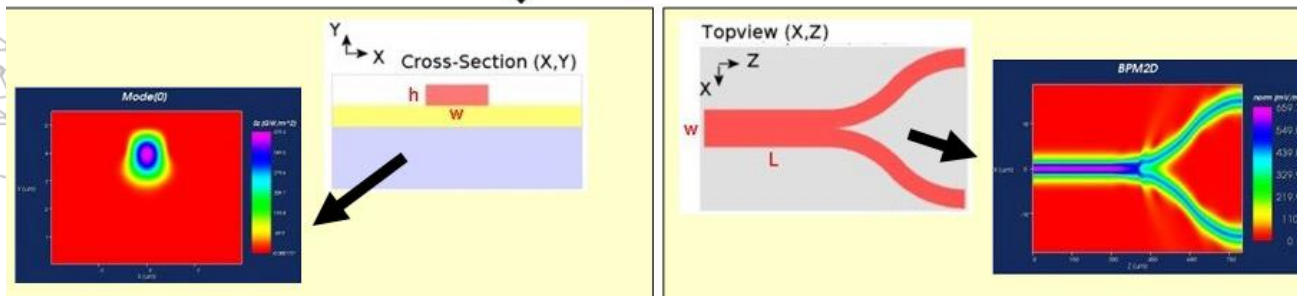
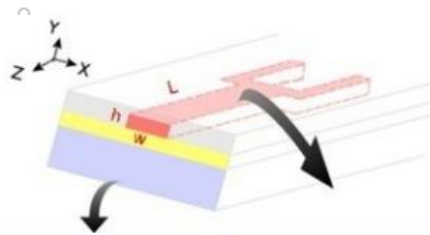
# PhoeniX Field- & OptoDesigner

- FieldDesigner

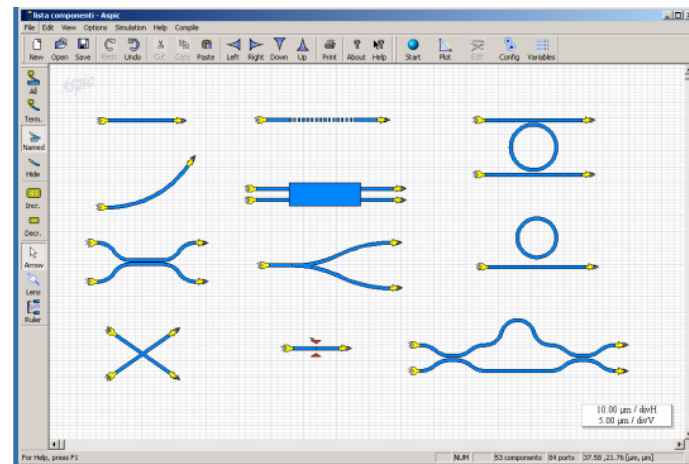
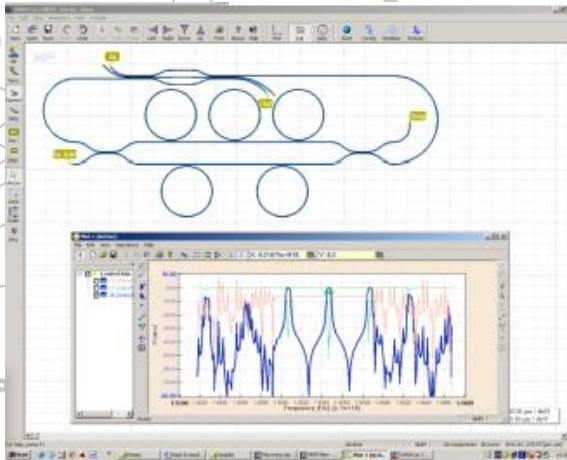
- FD and FMM mode solver (straight and bend waveguides)
- TO, EO, 3D ring resonator

- OptoDesigner

- Mode propagation simulation (BPM, BEP, FDTD)
- object oriented mask layout
- Automation for Functional DRC, mask assembly and GDSII generation



- Integrated photonics circuits simulation and design
- Allows analysis of larger / more complex circuits
- Response in spectral domain
  - Calculates amplitude, phase, group delay, dispersion, and polarization
- ASPIC comes with a large library of modules
  - Waveguides, bends, MMI's, rings, DC, splitter, MZ, phase modulator, crossings



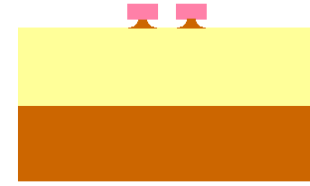
- Process flow virtualization
  - Based on process flow
  - Visualize cross section
- Library of different recipes & models
- Benefits
  - Essential for process development
  - Avoids costly mistakes
  - Improves yield

# PhoeniX FlowDesigner

step1: Si wafer



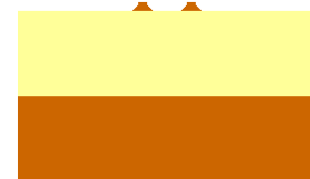
step6: Si core



step2: thermal oxide SiO2



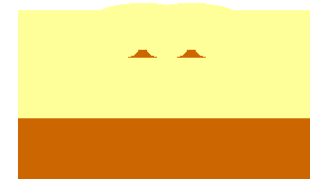
step7: Strip PhotoResist



step3: Si top layer



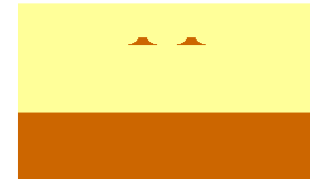
step8a: LPCVD SiO2 TEOS



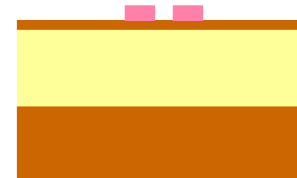
step4: PhotoResist deposit



Step 8b: CMP

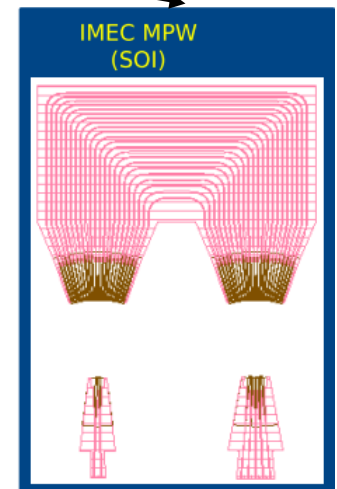
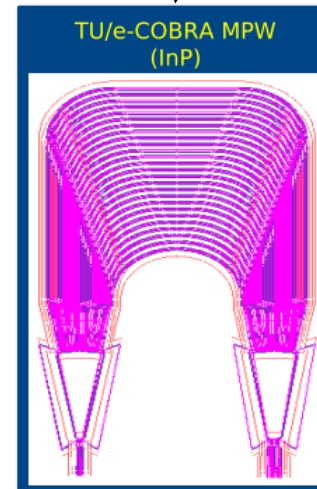
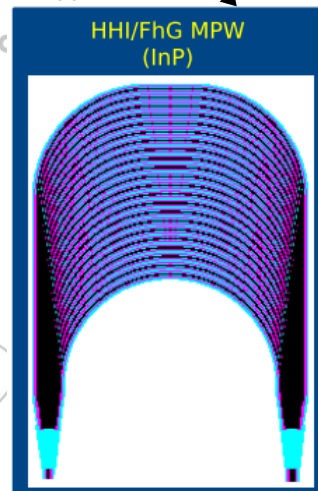
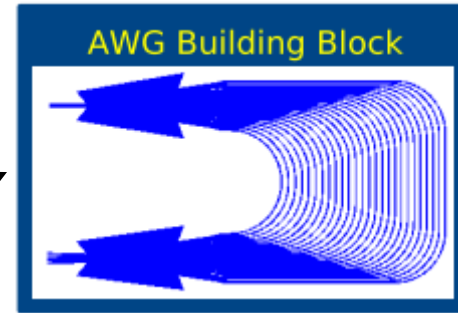
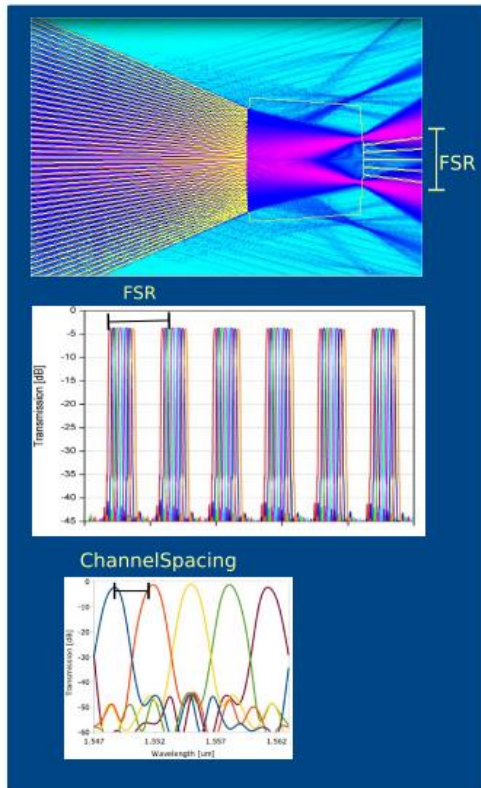


step5: pattern PhotoResist

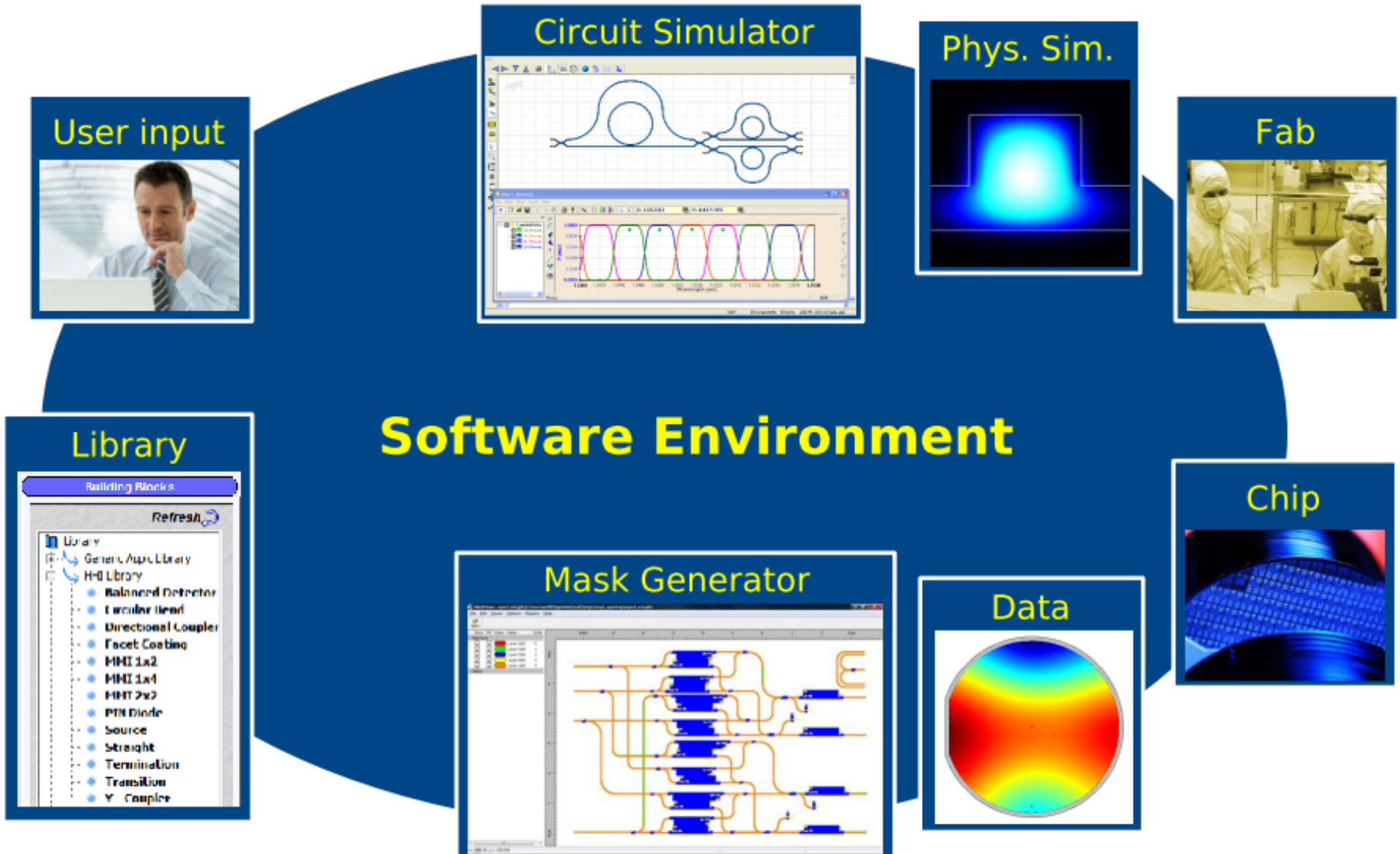


# Building blocks from PDKs

- Select technology
- Define specs
- Perform simulation
- Generate Design



# Integration of all different modules



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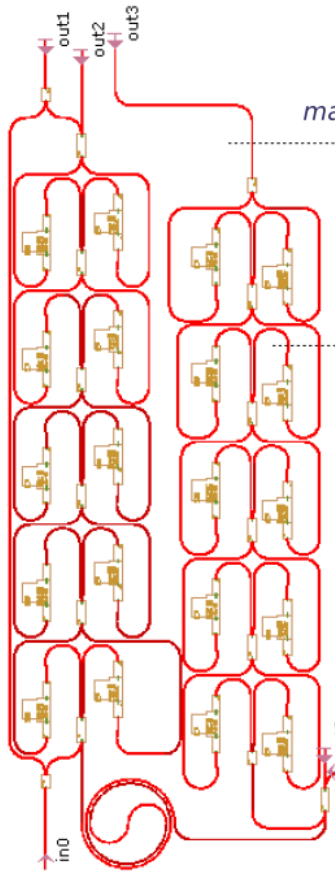
Circuit Simulator

Phys. Sim

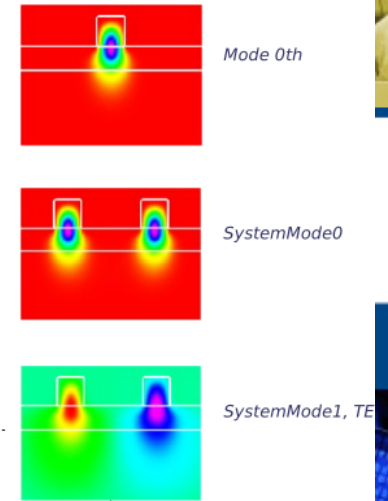
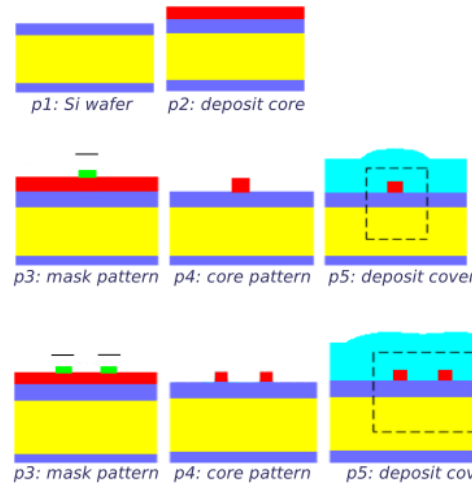
Mask layout

Process flow

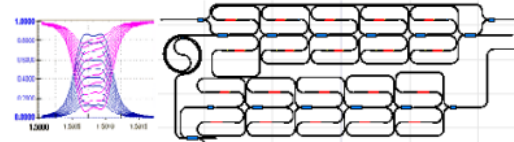
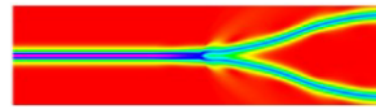
Mode solver



maskSliceLink



mode/field propagation



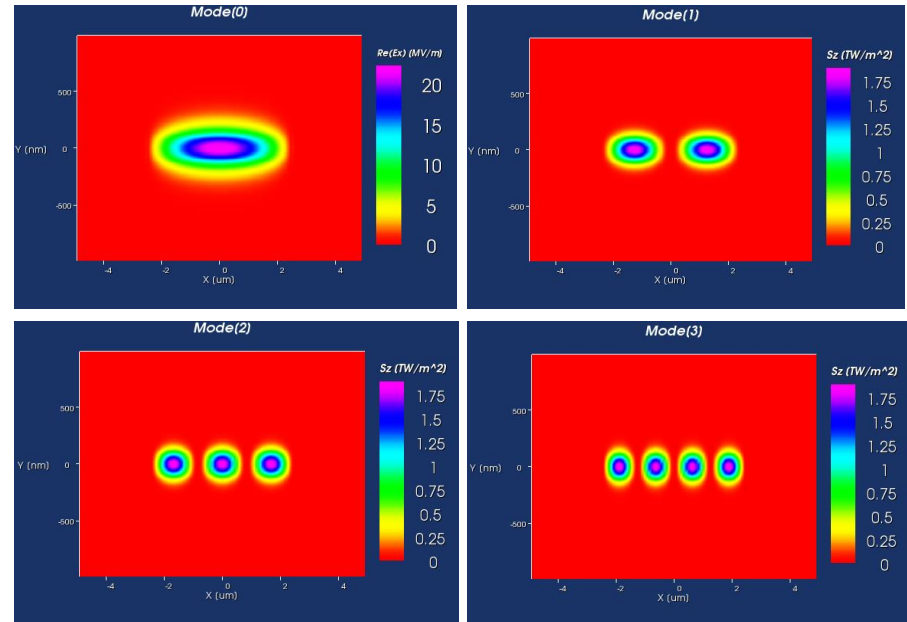
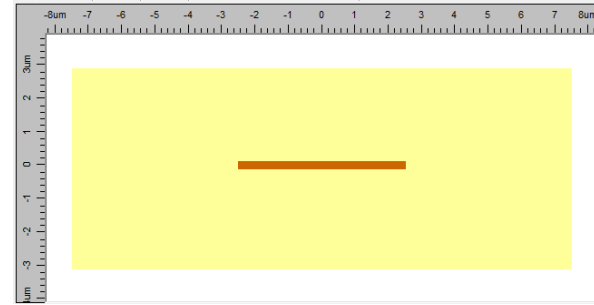
ASPIC





# Example: How to design an 1x2 MMI 1

1. Define waveguide (WG): width, height, material
2. Create WG cross-section in FieldDesigner (FD)
3. Set up simulation (algorithm, calculation window)
4. Find number of modes and their eff. refractive index for MMI's width with FD



# Example: How to design an 1x2 MMI 2

5. Import data from FD to OptoDesigner (OP)
6. Create top view of device in OP
7. Set up simulation
8. Use BPM simulation to find field distribution in MMI
9. Optimize MMI length, output port gap
10. Export mask

